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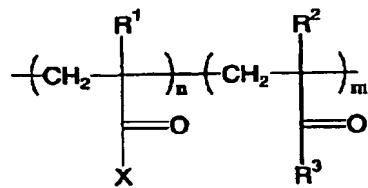
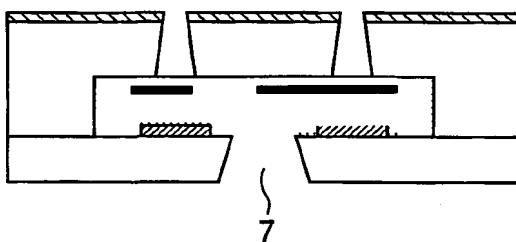
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(54) Title: PHOTORESISTIVE RESIN COMPOSITION, INK JET HEAD USING PHOTORESISTIVE RESIN COMPOSITION, AND PROCESS FOR MANUFACTURING INK JET HEAD



(1)

(57) Abstract: A positive type photo sensitive resin composition comprises a polyacrylate resin having, in the structure, at least a structural unit represented by the following general formula (1) wherein X represents a hydroxyl group, an alkylol group having 2 to 4 carbon atoms, or a methyolamino group, R1 and R2 independently represents a hydrogen atom, or an alkyl group having 1 to 3 carbon atoms, R3 represents an alkyl group having 1 to 3 carbon atoms, an alkoxy group having 1 to 3 carbon atoms, or an aralkyl group having an aryl group or alkyl group with 1 to 2 carbon atoms, n represents a positive integer, and m represents 0 or a positive integer, and m represents 0 or a positive integer, and a condensable crosslinker

WO 2006/001515 A1